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SJ

**INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

SJ 20984-2008

**General specification for chemical vapor deposition(CVD)
equipment**

化学气相淀积(CVD)设备通用规范
(English Translation)

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Table of Contents

What this standard covers	1
Document data	2
Standards quoted by this document	3

What this standard covers

This standard specifies the chemical vapor deposition equipment requirements, quality assurance provisions, delivery preparation. This standard applies to the electronics industry in photonics, microelectronics development and production of chemical vapor deposition equipment, and other similar equipment industry can also be implemented by reference.

Document data

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Standards quoted by this document

GB/T 191; GB/T 5080.7-1986; GB/T 6388; GB/T 5226.1-2002; GB/T 13384-1992; GB/T 37-1996; SJ 1276-1977; SJ/T 10674-1995